

L Number	Hits	Search Text	DB	Time stamp
2	1	438/174.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and (sidewall or spacer or side adj wall) near6 (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:09
3	106	438/174.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 09:39
4	27	((multiple near implant\$2) near2 (ldd or lightly near doped near drain) or mildd)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 09:40
5	8	("4356623"   "5372957"   "5376566"   "5382533"   "5393683"   "5405791"   "5422506"   "5512771").PN.	USPAT	2004/07/16 09:40
6	51	5719425.URPN.	USPAT	2004/07/16 09:41
7	16	("4784965"   "4951100"   "5091763"   "5274261"   "5324974"   "5334870"   "5422506"   "5663586"   "5719425"   "5789298"   "5801077"   "5821146"   "5847428"   "5869866"   "5895955"   "5950091").PN.	USPAT	2004/07/16 09:51
8	2	438/185.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:11
9	6	438/194.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:16
10	13	("4366613"   "4753898"   "5376566"   "5439835"   "5496751"   "5534449"   "5631485"   "5719424"   "5736440"   "5747855"   "5877530"   "6187620"   "6194279").PN.	USPAT	2004/07/16 10:13
11	22	438/217.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:26
12	77	438/231.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:39
13	32	438/232.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:47

14	56	438/289.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 10:56
15	192	438/305.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 11:09
16	69	438/306.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions or implant or implanting or doping))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 11:10
-	2035	438/305.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 16:11
-	275	438/305.ccls. and (plural or multiple or third or plurality) near2 (region or area or doping or concentration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 16:12
-	281	438/305.ccls. and (plural or multiple or third or plurality) near2 (region or area or doping or concentration or subregion)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 17:22
-	19	("5348900"   "5460993"   "5637514"   "5641698"   "5719425"   "5789298"   "5866460"   "5920782"   "5963814"   "5966611"   "5970358"   "5981345"   "5998274"   "6124614"   "6140186"   "6187645"   "6261913"   "6350665"   "6383881").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT	2004/07/15 16:22
-	16	("4356623"   "4786609"   "5147811"   "5171700"   "5183771"   "5376566"   "5382533"   "5393683"   "5405791"   "5424234"   "5441906"   "5534449"   "5573965"   "5620919"   "5677224"   "5705439").PN.	USPAT	2004/07/15 16:23
-	6	6258680.URPN.	USPAT	2004/07/15 16:42
-	16	("4784965"   "4951100"   "5091763"   "5274261"   "5324974"   "5334870"   "5422506"   "5663586"   "5719425"   "5789298"   "5801077"   "5821146"   "5847428"   "5869866"   "5895955"   "5950091").PN.	USPAT USPAT	2004/07/15 16:42
-	35	438/305.ccls. and (grading or grade or graded) near4 ldd	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 17:52

-	37	("3660735"   "4149904"   "4198250"   "4356623"   "4697333"   "4703551"   "4745086"   "4760033"   "4859618"   "4935379"   "4949136"   "5147811"   "5185280"   "5217910"   "5227321"   "5244823"   "5272367"   "5296401"   "5321283"   "5395773"   "5401994"   "5405791"   "5424567"   "5439834"   "5482878"   "5489546"   "5500379"   "5534449"   "5536959"   "5595919"   "5614432"   "5650343"   "5654212"   "5719425"   "5747852"   "5866460"   "6004843").PN.	USPAT	2004/07/15 17:48
-	991	gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and sidewall with (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 17:55
-	600	gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and sidewall near4 (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 18:31
-	6	438/163.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and sidewall near4 (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/15 18:32
-	12	438/163.ccls. and gate and source and drain and (source or drain or ldd) near3 (graded or grading or (plural or multiple or plurality or third or three or several) near2 (areas or regions or subregions or portions)) and (sidewall or spacer or side adj wall) near6 (doping or doped or dopant or implant or implanting or implanted or impurity or aligned or alignment)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/16 09:30